

Patterned Nitroxide Polymer Brushes for Thin-Film Cathodes in Organic Radical Batteries†

Yu-Hsuan Wang, Miao-Ken Hung, Chun-Hao Lin, Hsiao-Chien Lin and Jyh-Tsung Lee*

Department of Chemistry and Center for Nano Science and Nano Technology, National Sun Yat-Sen University, Kaohsiung, Taiwan.

Tel: +886 7 525 3951

**E-mail: jtlee@faculty.nsysu.edu.tw*

Contents

1. Materials	S2
2. Instruments	S2
3. Synthesis of the surface initiator	S3
4. Synthesis of PTMA brushes	S4
5. Electrochemical measurements of PTMA brushes	S6
6. Optical microscope images of patterned PTMA brushes	S7
7. MNR spectra	S8
8. AFM images and Surface roughness	S10
9. XPS spectra	S11

1. Materials.

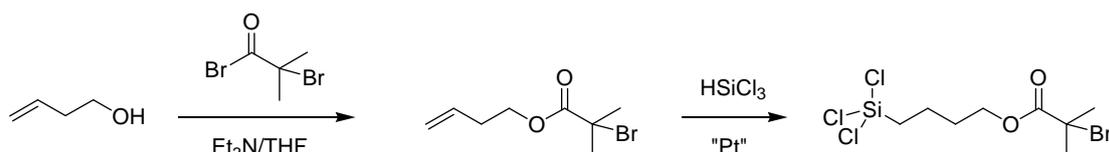
3-Buten-1-ol (98 %), 2,2,6,6-tetramethylpiperinyl methacrylate (TMPM, 98%), tetra-*n*-butylammonium perchlorate (98%) were obtained from TCI. 2-Bromo-2-methylpropionyl bromide (98%), copper (I) bromide (CuBr, 99.999%), Karstedt's catalyst (~ 2% Pt), and 1,1,4,10,10-hexamethyltriethylenetriamine (HMTETA, 99+%), and ITO/PET film (surface resistivity: 35 ohm/sq) were purchased from Aldrich. ITO/glass (surface resistivity: 10 ohm/sq) was purchased from UniRegion Bio-Tech. Trichlorosilane (>98%), sulfuric acid (97%), and hydrogen peroxide (35%) were obtained from Showa. Poly(dimethylsiloxane) (PDMS, Sylgard 184A) and its crosslinker (Sylgard 184B) were obtained from Gelest. *n*-Octadecyltrichlorosilane (OTS, 85%) and 3-chloroperoxybenzoic acid (*m*CPBA, 70~75%) were obtained from Alfa Aesar and Acros, respectively. Except for *m*CPBA, all chemicals were used as received. *m*CPBA was recrystallized in methanol.

2. Instruments.

An X-ray photoelectron spectroscopy (XPS, ULVAC-PHI, PHI Quantera SXM) with a focused monochromatic Al K α radiation (1486.6 eV) was used to analyze the composition of the polymer brushes/ITO. ^1H - and ^{13}C -NMR spectra were acquired using a 500 MHz and a 125 MHz NMR Bruker spectrometer, respectively. Gel permeation chromatography (GPC) measurements were determined on a Shimadzu system in DMF using a Waters' column at 45°C, the calibration was performed using a series of polystyrene standards. The surface morphology and root mean squares (rms) of the polymer brushes ITO/glass were observed using an atomic force microscope (AFM, Nano-Man NS4+D3100). Electrochemical properties were obtained on a CHI model 6081 electrochemical analytical instrument.

3. Synthesis of the surface initiator

The surface initiator, (4-(2-bromo-2-methyl)propionyloxy)butyltrichlorosilane (BMPBTS), was synthesized according to the method of Matyjaszewski et al, as shown in Scheme S1.



Scheme S1. Synthesis of (4-(2-bromo-2-methyl)propionyloxy)butyltrichlorosilane

Synthesis of but-3-enyl-2-bromo-2-methylpropanate

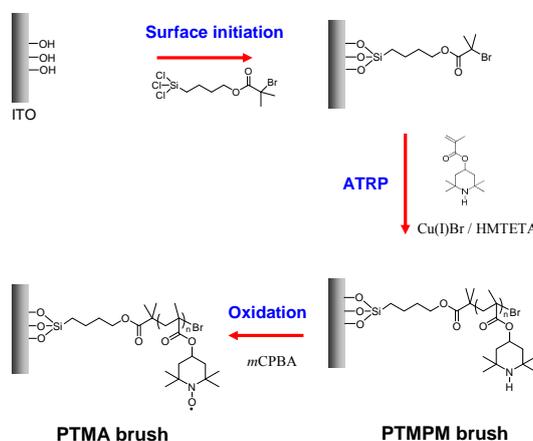
3-Buten-1-ol (2.47 mL, 0.02 mol) and triethylamine (2.79 mL, 0.02 mol) were dissolved in 25.0 mL of tetrahydrofuran. 2-Bromo-2-methylpropionyl bromide (1.76 mL, 0.02 mol) was slowly added to the above solution at room temperature under a nitrogen atmosphere. After stirring for three hours, the reaction was terminated. The solution was filtered by a short aluminum oxide column to remove the salt. Finally, the solvent was removed by a rotavapor to yield but-3-enyl-2-bromo-2-methylpropanate (2.68 g, 0.13 mol). Yield: 66%. ¹H-NMR (500 MHz, CDCl₃, TMS as standard): δ 5.81 (1H, ddt, *J* = 17.0, 10.0, 6.5 Hz, CH₂CHCH₂), 5.14 (1H, dd, *J* = 10.0, 7.0 Hz, CH₂CHCH₂), 5.10 (1H, dd, *J* = 17, 1.5 Hz, CH₂CHCH₂), 4.23 (2H, t, *J* = 6.5 Hz, CH₂CH₂O), 2.45 (2H, q, *J* = 6.5 Hz, CH₂CH₂O), 1.93 (6H, s, CH₃). ¹³C-NMR (125 MHz, CDCl₃): δ 171.6 (CH₂OCO), 133.6 (CH₂CHCH₂), 117.5 (CH₂CHCH₂), 64.9 (CH₂CH₂O), 55.8 (COCB_r), 32.8 (CHCH₂CH₂O), 30.8 (C(CH₃)₂Br). MS (ESI): calculated for C₈H₁₂O₂Br: [M+Na]⁺, 242.9997 [M+Na]⁺, found [M+Na]⁺, 242.9999).

Synthesis of BMPBTS

But-3-enyl 2-bromo-2-methylpropanoate (0.23 g, 1.02 mmol) was dissolved in 1.0 mL of trichlorosilane under a nitrogen atmosphere. A Karstedt's catalyst (30 μ L) was added into the above solution. After stirring for five hours, the excess trichlorosilane was removed under reduced pressure to get BMPBTS (0.32 g, 0.91 mmol). Yield: 89%. $^1\text{H-NMR}$. (500 MHz, CDCl_3 , TMS as standard): δ 4.22 (2H, t, $J = 6$ Hz, $\text{CH}_2\text{CH}_2\text{O}$), 1.93 (6H, s, CH_3), 1.83 (2H, p, $J = 6$ Hz, SiCH_2CH_2), 1.73 (2H, m, $\text{CH}_2\text{CH}_2\text{O}$), 1.46 (2H, t, Cl_3SiCH_2). $^{13}\text{C-NMR}$ (125 MHz, CDCl_3): δ 171.7 (CH_2OCO), 64.9 ($\text{CH}_2\text{CH}_2\text{O}$), 55.7 (COCBR), 30.7 ($\text{C}(\text{CH}_3)_2\text{BR}$), 30.3 ($\text{CH}_2\text{CH}_2\text{CH}_2\text{O}$), 23.7 ($\text{Cl}_3\text{SiCH}_2\text{CH}_2$), 18.8 (Cl_3SiCH_2).

4. Synthesis of PTMA Brushes

The attachment of surface initiator and the subsequent surface-initiated polymerization of 2,2,6,6-tetramethyl-piperinyl methacrylate on a ITO glass were carried out by ATRP. Poly(2,2,6,6-tetramethylpiperinyl-4-yl methacrylate), PTMPM, brushes were oxidized by *m*-chloroperoxybenzoic acid (*m*CPBA) in dichloromethane to give nitroxide polymer brush/ITO substrates.



Scheme S2. Synthesis of PTMA Brushes

Attachment of surface initiator

An ITO substrate was cleaned by RCA method (DI water : ammonia : hydrogen peroxide = 5:1:1 in volume).¹ The cleaned ITO substrate was immersed in a 10 mM surface-initiator, BMPBTS, toluene solution at 80°C for 30 minutes. Then, the initiator-attached ITO substrate was ultrasonicated in toluene for 10 minutes. Finally, the ITO substrate was dried by a nitrogen stream.

Surface-initiated ATRP of TMPM

CuBr (21.6 mg, 0.15 mmol) and HMTETA (42 μ L, 0.15 mmol) were dissolved in 15 mL of acetone and degassed by four freeze-pump-thaw cycles.² The above solution was transferred *via* a cannula into a degassed flask containing TMPM (0.94 g, 15.0 mmol) as a monomer. Finally, the above solution of the monomer and the catalyst was transferred by a cannula into a degassed container containing the initiator-attached ITO substrate. The polymerization was carried out at reflux under a nitrogen atmosphere for a predetermined time to give a PTMPM brush. The PTMPM brush/ITO substrates were rinsed and ultrasonicated with acetone. Finally, they were dried in a nitrogen stream.

PTMA brush on ITO: Oxidation of the TMPM brush

A TMPM brush on ITO was immersed in a 5 mL dichloromethane solution of *m*CPBA (8.7 mg) at room temperature for 10 minutes. The oxidized TMPM brush on ITO was ultrasonicated with several solvents, such as dichloromethane, hexane, and acetone and then dried in a nitrogen stream.

5. Electrochemical measurements of PTMA brushes

For the electrochemical cell, a PTMA brush/ITO electrode was used as a working electrode; platinum wire was used for the counter electrode. The reference electrode was Ag/AgNO₃ (0.01 AgNO₃ and 0.1 M tetra-*n*-butylammonium perchlorate, (C₄H₉)₄NClO₄, in acetonitrile); the electrolyte was 0.1 M (C₄H₉)₄NClO₄ in acetonitrile. For the cyclic voltammogram (CV), the cells were observed between 0.0 to 0.6 V at a scan rate of 5.0 mV/s. The half cells were cycled at a constant current at the 10 C rate between 0.3 and 0.55 V.

In the lithium-ion battery, a PTMA brush ITO/PET electrode was used as a working electrodes; a lithium metal foil was used for the counter and reference electrodes. A separator (Celgard 2320) was placed between the PTMA brush/ITO electrode and the lithium counter electrode. The electrolyte was 1.0 M LiPF₆ in EC/PC/DEC (= 3/2/5 in volume). For the cyclic voltammogram (CV), the cell was observed between 3.2 to 4.0 V at a slow scan rate of 0.1 mV/s.

6. Optical microscope images of patterned PTMA brushes

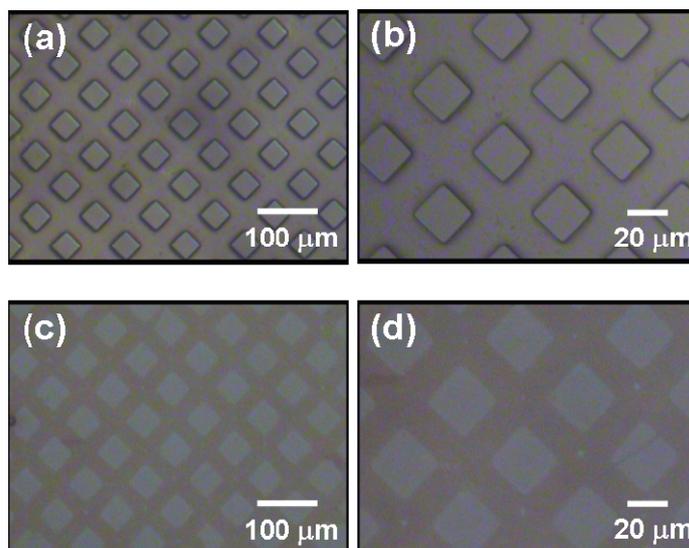


Fig. S1 Optical microscope images for (a) and (b) a grid-patterned PDMS stamp; (c) and (d) a grid-patterned PTMA brush (dark regions) on ITO.

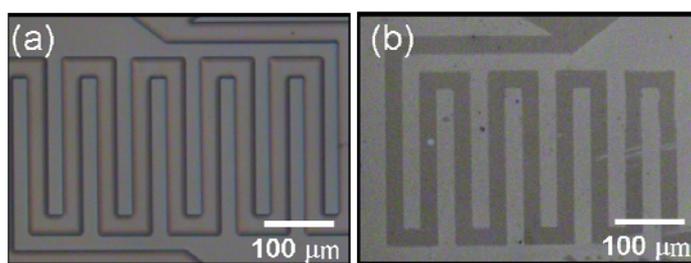


Fig. S2 Optical microscope images for (a) a patterned PDMS stamp; (b) a patterned PTMA brush (dark regions) on a Si substrate.

7. NMR Spectra

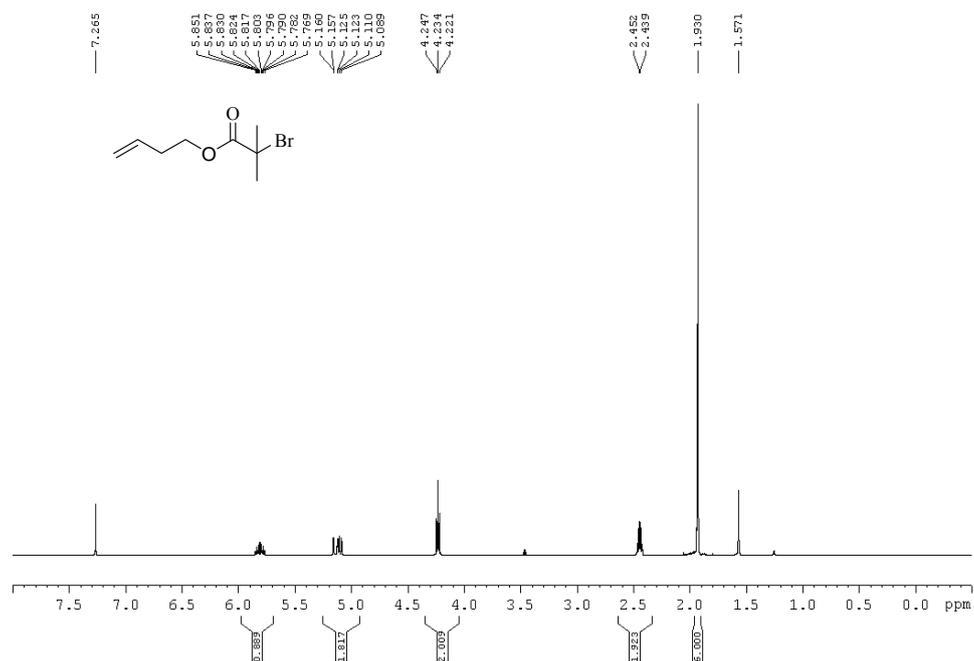


Fig. S3 ¹H-NMR spectrum for but-3-enyl-2-bromo-2-methylpropanate.

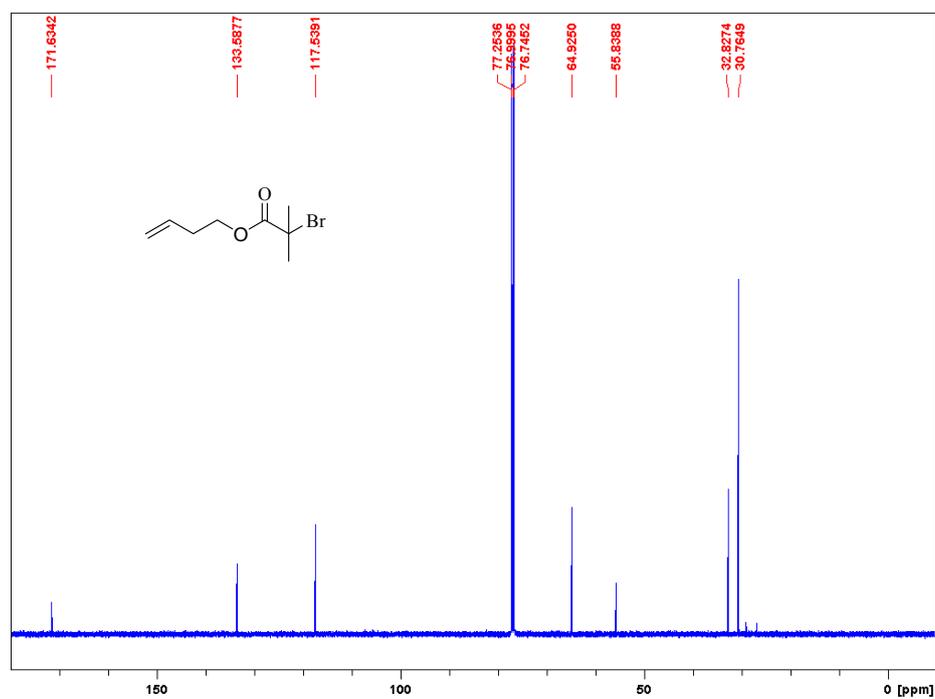


Fig. S4 ¹³C-NMR spectrum for but-3-enyl-2-bromo-2-methylpropanate.

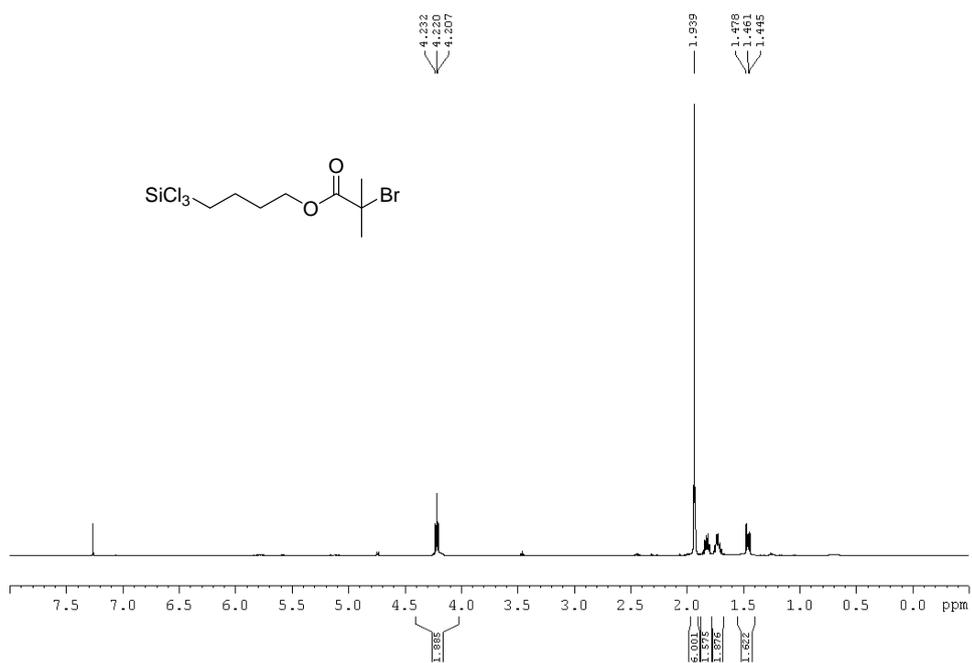


Fig. S5 $^1\text{H-NMR}$ spectrum for 4-(2-bromo-2-methyl)proionyloxy)butyltrichlorosilane.

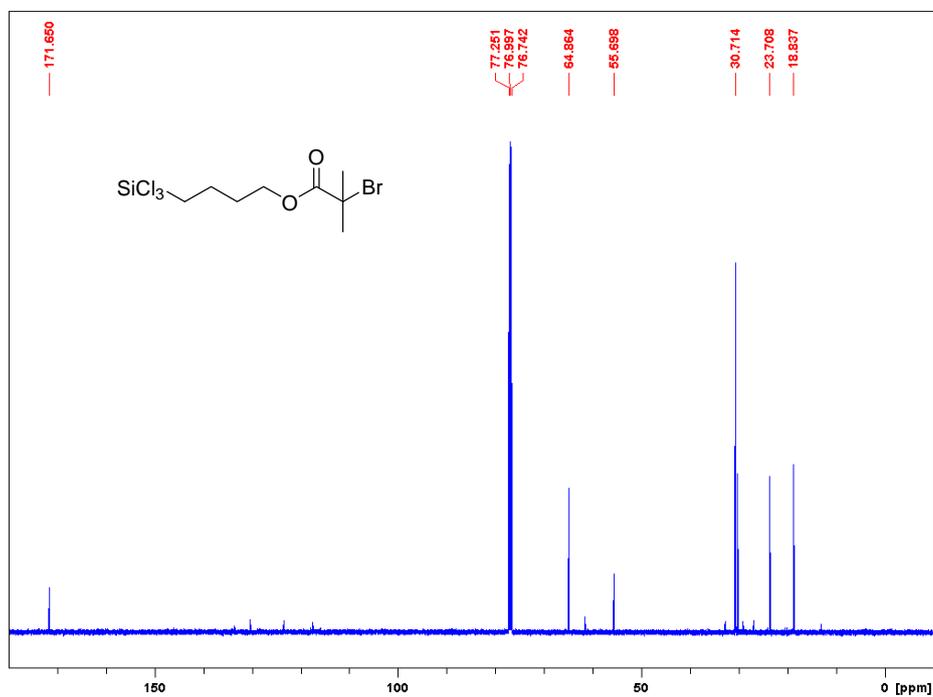


Fig. S6 $^{13}\text{C-NMR}$ spectrum for 4-(2-bromo-2-methyl)proionyloxy)butyltrichlorosilane.

8. AFM images

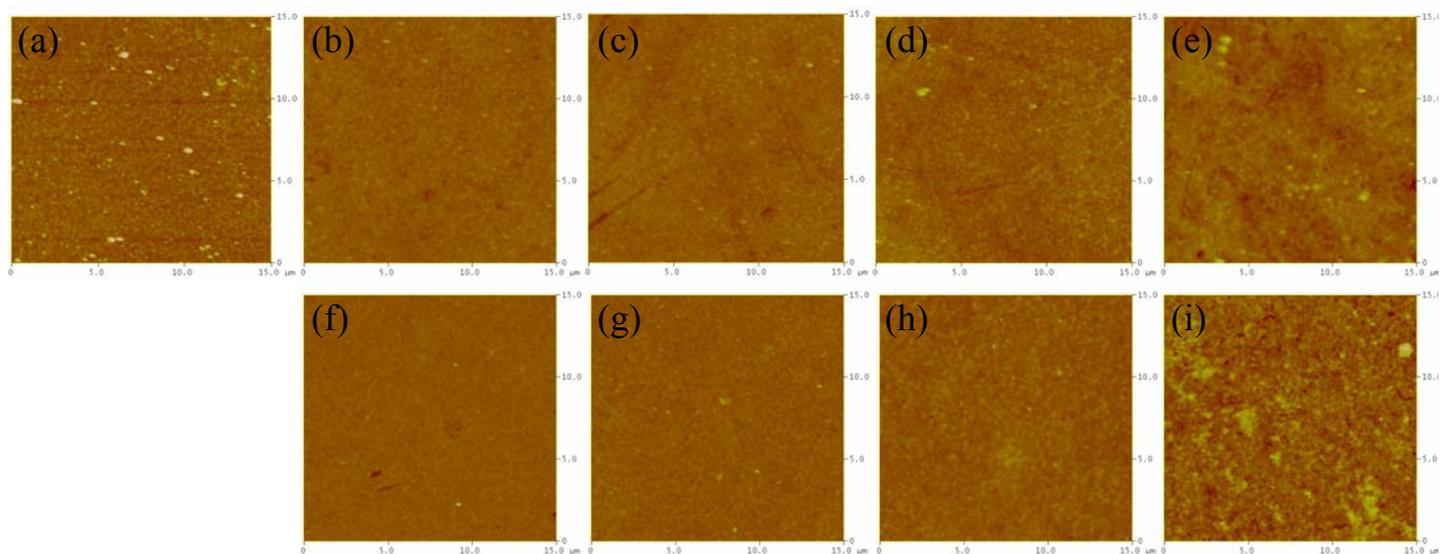


Fig. S7 AFM images for (a) blank ITO/ITO, (b-e) initiator-attached ITO substrates being polymerized with the PTMPM brush using ATRP for 2, 3, 4, and 5 hours, respectively, and (f-i) the specimens of (b-e) after the oxidation using *m*CPBA for 10 minutes, respectively.

Table S1 Surface roughness measured by AFM on PTMPM and PTMA brushes polymerized for 2, 3, 4, and 5 hours.

polymerization time (hours)	rms roughness	
	PTMPM brush (nm)	PTMA brush (nm)
2	1.17	2.00
3	1.29	2.23
4	1.82	3.12
5	2.50	3.74

* The rms roughness of blank ITO is 2.39 nm.

9. XPS spectra

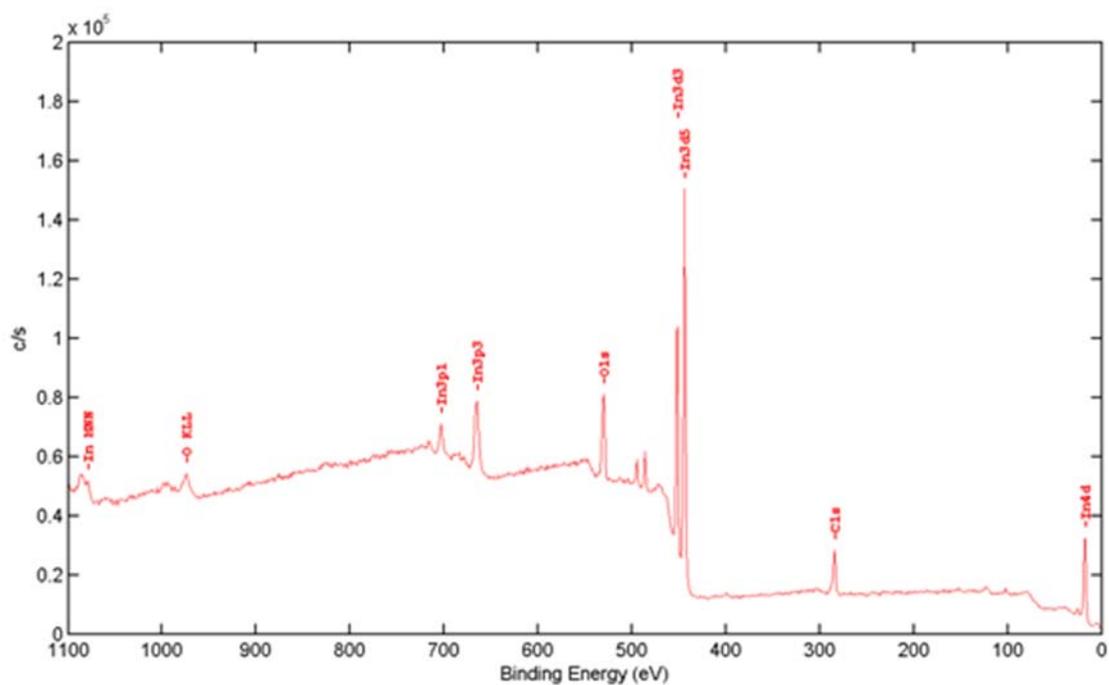


Fig. S8 XPS survey spectrum for 4-(2-bromo-2-methyl)proionyloxy)butyltrichlorosilane grafted on ITO.

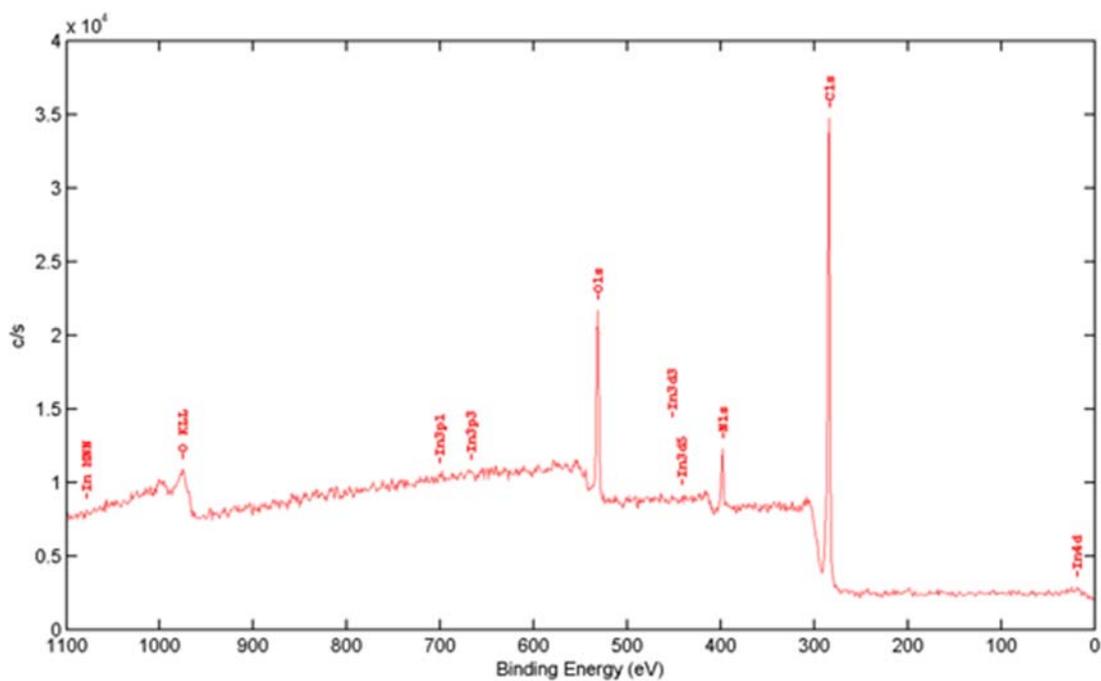


Fig. S9 XPS survey spectrum for the PTMPM brush on ITO.

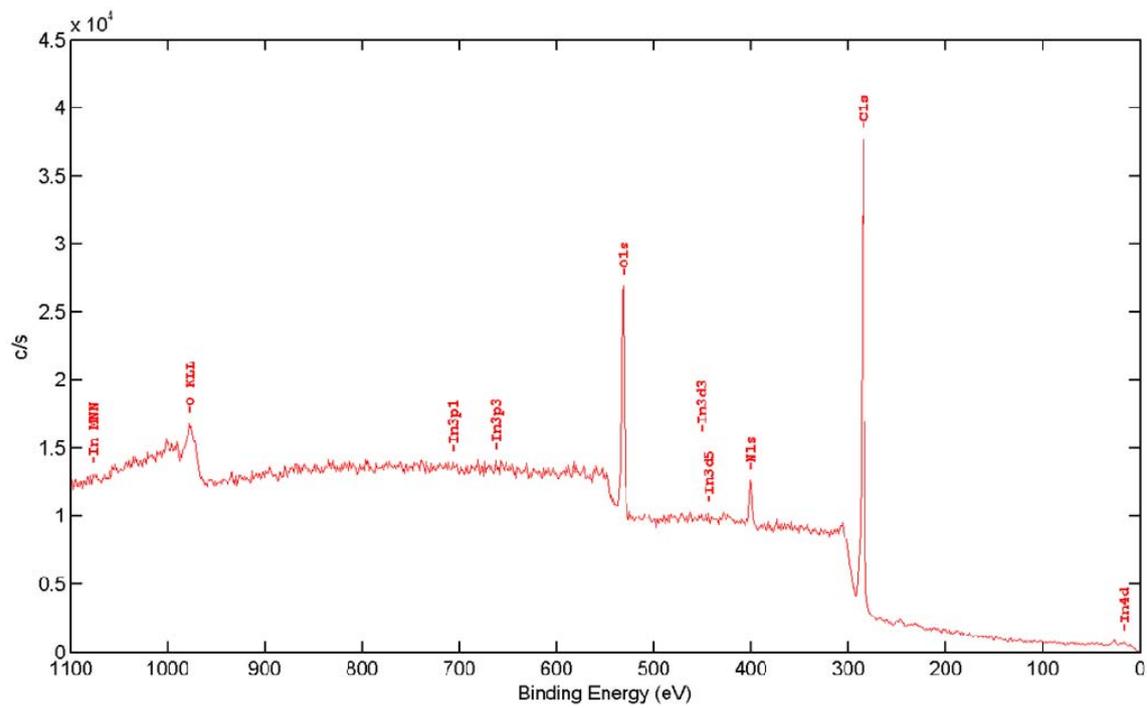


Fig. S10 XPS survey spectrum for the PTMA brush on ITO.